Slater & Matsil, L.L.P.

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FACSIMILE COVER SHEET

To Examiner: Jeffrey C. Mullis

Total Pages Sent:

11

Mail Stop: Amendment

(including cover sheet)

Facsimile Number: 571-273-8300

Transmission Date:

October 10, 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Hsu, et al.

Docket No.:

TSM02-1205

Serial No:

10/615,628

Art Unit:

1711

Date Filed:

July 9, 2003

Title:

Process for Improving Dielectric Properties in Low-K Organosilicate Dielectric

Material

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the following papers are being transmitted by facsimile to the U.S. Patent and Trademark Office at 571-273-8300 on the date shown above:

- Certification of Facsimile Transmission (1 page)
- Amendment (8 pages)
- Amendment Transmittal Letter (1 original & 1 copy)

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Respectfully submitted.

OCT 1 1 2005

gudy A. Betts Legal Assistant

Confirmation Respectfully Requested

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PAGE 02/11

OCT 1 0 2005

AMENDMENT TRANSMITTAL LETTER					Attorney Docket No: TSM02-1205	
Application Serial Number: 10/615,628		Filing Date: 7/9/2003		Examiner: Jeffrey C. Mullis		Art Unit: 1711
Invention: Process for Improving Dielectric Properties in Low-K Organosilicate Dielectric Material						
TO THE COMMISSIONER FOR PATENTS: Transmitted herewith is an amendment in the above-identified application. The fee has been calculated as shown below.						
CLAIMS AS AMENDED						
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR	NO. OF EXTRA CLAIMS PRESENT	RATE	ADDITIONAL FEE
TOTAL CLAIMS	14	MINUS	20	0	\$50	\$ 0.00
INDEP. CLAIMS	5	MINUS	4	1	\$200	\$ 200.00

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9727329218

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Material

Mail Stop: Amendment Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed July 14, 2005. Please amend the above-referenced application as follows.

10/12/2005 EFLORES 00000018 501065 10615628

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